

ABSTRACT

An LCD device and a method for manufacturing the same are disclosed, in which a width of a gate line is decreased by forming a storage capacitor of a high capacitance with a small area, and by improving an aperture ratio, thereby obtaining high picture quality.

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Figure 1 is a plan view of a liquid crystal display (LCD) device according to an embodiment of the present invention. The LCD device includes a substrate 100, a gate line 110, a data line 120, a storage capacitor 130, and a pixel 140. The gate line 110 and the data line 120 are formed on the substrate 100. The storage capacitor 130 is formed on the substrate 100 and is connected to the gate line 110 and the data line 120. The pixel 140 is formed on the substrate 100 and is connected to the gate line 110 and the data line 120. The storage capacitor 130 is formed on the substrate 100 and is connected to the gate line 110 and the data line 120. The pixel 140 is formed on the substrate 100 and is connected to the gate line 110 and the data line 120.